

**REMARKS**

In the Notice of Allowability, the Examiner states that the drawings filed on 11/24/04 are not accepted and requests Applicants to submit corrected drawings.

Applicants are submitting herewith the corrected drawings. Also attached is a marked-up copy of the original drawings with the changes noted.

Applicants wish to point out that drawings are only for illustration purpose and only represent one embodiment of the invention. A skilled person would know that photomasks used for imagewise exposure determine the area(s) of the photoresist (5) removed. Therefore depending on the size and shape of the openings of the photomask, the amount of the photoresist removed can be controlled.

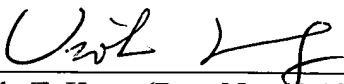
The Examiner is requested to consider and enter the Amendment after Allowance.

**CONCLUSION**

Applicants believe that the application is in good and proper condition for allowance. Early notification of allowance is earnestly solicited. If, in the opinion of the Examiner, a telephone conference would expedite the prosecution of the subject application, the Examiner is encouraged to call the undersigned.

Respectfully submitted,

Date: March 16, 2005

  
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Enclosures

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Application Serial No. 10/797,544  
Attorney's Docket No. 07783.0011.CNUS03

**In the Drawings:**

Please see the attached corrected drawings.



Marked-Up Version

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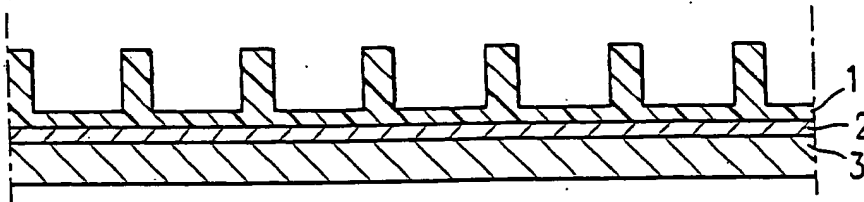


FIG. 1A

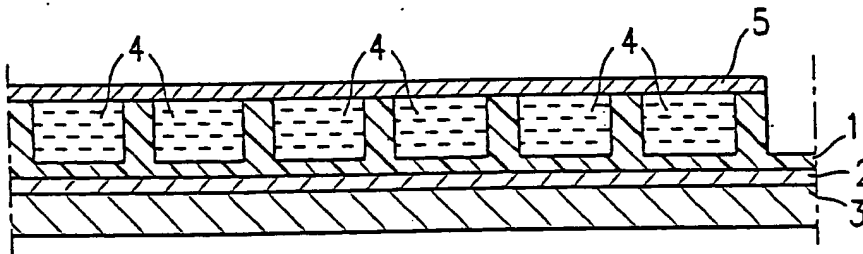


FIG. 1B

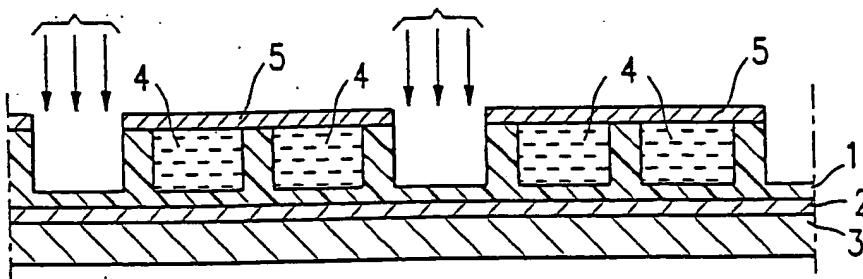


FIG. 1C

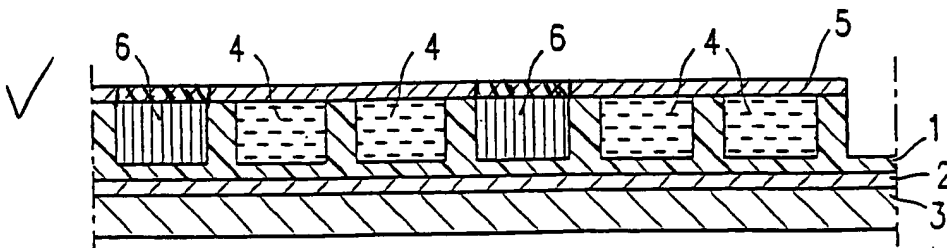


FIG. 1D

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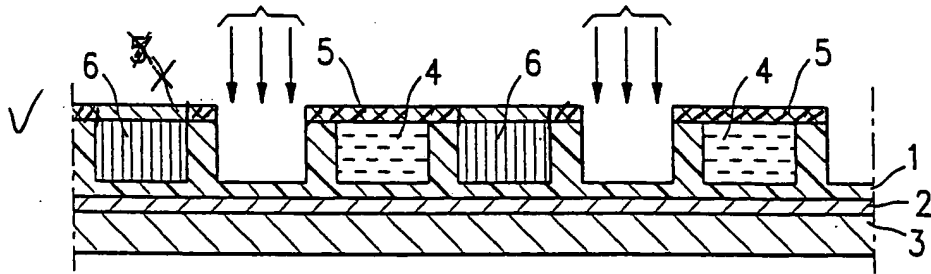


FIG. 1E

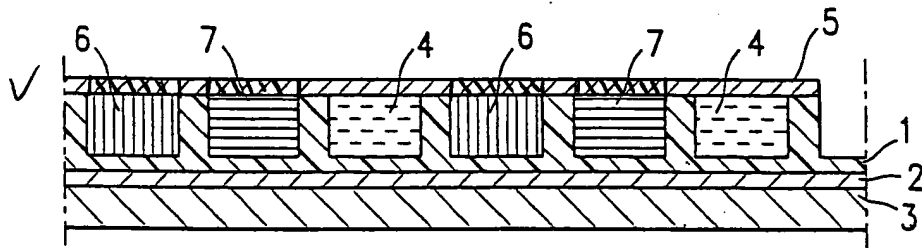


FIG. 1F

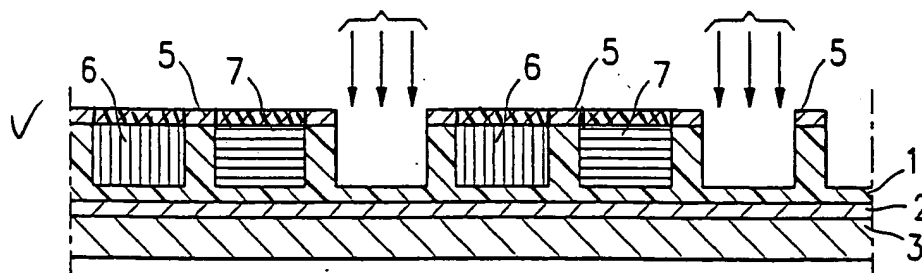


FIG. 1G

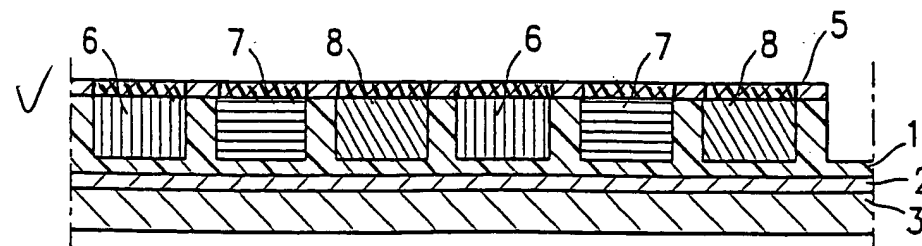


FIG. 1H